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Surface Energy and Microstructure: The effect of the underlying substrate on perovskite film formation for solar cell absorbers

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Introduction & Background

Pb-Based Perovskite Films as an Emerging PV Absorber

Record devices are over 20% efficient but there are materials problems that need to be solved [1].

Interfacial modification affects:

- Film uniformity
- Crystallinity
- Grain size
- Defect density

Small molecule modifiers and their positive effects on device performance. Data from references [2] and [4].

Modifier	Stack Structure	V _{oc} [V]	J _{sc} [mA cm ⁻²]	PCE [%]
Bromobenzoic Acid (<i>Br-BA</i>) [2]	ITO/NiO _x / MAPbI ₃ /PCBM /bis-C ₆₀ /Ag	1.07	19.1	15.3
	ITO/NiO _x / Br-BA / MAPbI ₃ /PCBM /bis-C ₆₀ /Ag	1.11	21.7	18.4
(3-Aminopropyl) triethoxysilane (APTES) [4]	FTO/SnO ₂ / MAPbI ₃ / Spiro- OMeTAD/Au	1.065	20.84	14.69
	FTO/SnO ₂ / APTES / MAPbl ₃ / Spiro- OMeTAD/Au	1.16	21.23	17.03

Contact Charge transport layer (CTL) Absorber Molecular modifiers Metal Oxide CTL Transparent conductive oxide Superstrate Glass

Goal: Improve stability of perovskite-TCO interface.

Chemical process of small molecule modification of a metal oxide.

Device properties and performance are directly tied to perovskite film properties [3].

perovskite absorbers through small molecule modification of

> **Materials** Design for Device **Materials** Reliability Synthesis & **Fabrication** & Optimization Characterization Anneal

> > Lifetime

Interfacial Modification and Stability

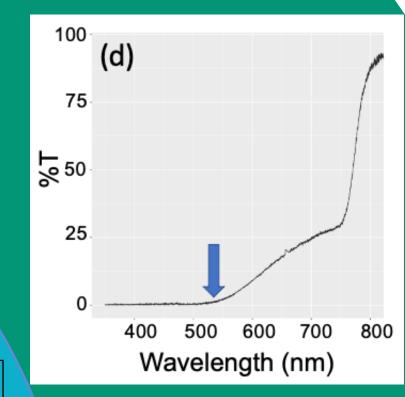
BPTMS and MAPbl₃ Grain Growth

- BPTMS leads to growth of smaller grains on ITO
- MAPbl₃ grains on s-ITO comparable in size to those grown on glass

"s-" denotes inclusion of BPTMS interlayer Glass + MAPbl₃ ITO + MAPbl₃ s-ITO + MAPbl₃

Results: BPTMS passivates the perovskite-TCO interface, affecting both the film morphology and degradation profile of the perovskite.

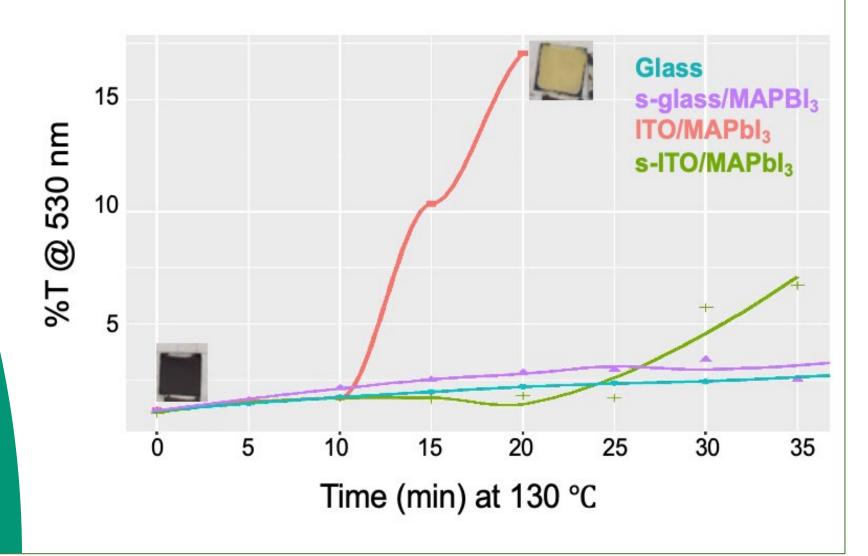
Voltage (V)



UV-Vis spectrum of MAPbl₃ on s-ITO.

BPTMS and MAPbl₃ Degradation

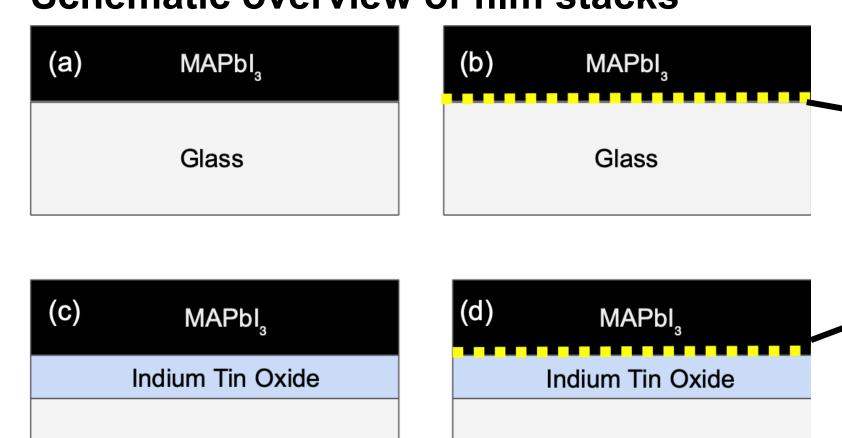
- BPTMS mitigates MAPbl₃ degradation on ITO (in green) compared to the unmodified control (in red)
- Decouples effects of grain size from interfacial chemistry in terms of stability



Experimental Flow

- 1. Clean substrates
- 2. Deposit organofunctional silane [6,7]
- 3. Spin coat MAPbl₃ and anneal [5]
- 4. Characterization and degradation

Schematic overview of film stacks



Dashed line indicates organofunctional silane layer.

Substrate	Thicknes s, Å	Contact Angle, degrees
Silicon	11 ± 1	62 ± 3
	24 ± 1	81 ± 2
	34 ± 2	84 ± 1
ITO	6 ± 1	72 ± 2

Glass

Left: Characteristics of BPTMS modified ITO and silicon. Silane thickness is modelled from spectroscopic ellipsometry measurements.

Glass

Right: SE characterization of perovskite films

Silane and Perovskite Deposition

Approach: Deposition of MAPbl₃ on bare and silane-modified substrates to systematically investigate effects of a BPTMS interlayer on perovskite degradation.

> 3-Bromopropyl trimethoxysilane [BPTMS]

Enhancement Molecular structure of

> Further investigate silane-MO interface and its effects on the perovskite film with SE and XPS

Future Directions:

- Apply silanes to MOs (Metal Oxides), commonly used as PV charge transport layers
- Investigate systematically varied TCO/MO/silane combinations in halfstack degradation studies

Conclusions

- Results highlight importance of film studies under device-relevant conditions
- Organofunctional silanes used as molecular modifiers can passivate a TCO/perovskite interface
- Interfacial modifiers have multifaceted effects on perovskite film morphology and lifetime

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Conclusions and Future Directions